

AUG 20 2008

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Company:	US Patent Office	Date:	August 20, 2008
Fax:	(571) 273-8300	Pages:	4 (including cover sheet)
Your Re:	10/764,193	Our Re:	ITL.1056US

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AUG 20 2008

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:	Michael L. McSwiney et al.	§	Art Unit:	1792
Serial No.:	10/764,193	§	Examiner:	David P. Turocy
Filed:	January 23, 2004	§	Atty Docket:	ITL.1056US P17793
For:	Forming a Silicon Nitride Film	§	Assignee:	Intel Corporation

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY TO FINAL REJECTION

Sir:

In response to the final rejection mailed July 18, 2008, please amend the above-referenced patent application as follows:

Date of Deposit: August 20, 2008
I hereby certify that this document is being facsimile transmitted to the
United States Patent and Trademark Office (Fax No. 571-273-8300) on the
date indicated above.
Cynthia L. Hayden
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